ED STATES PATENT AND TRADEMARK OFFICE

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In re Application of:

MAR : 2 2002

Reimer, et al.

Serial No.: 09/220,153

Confirmation No.: Unknown

Filed:

December 23, 1998

Processing Apparatus Having

Integrated Pumping System

Assistant Commissioner for Patents

Washington, D.C. 20231

Dear Sir:

Group Art Unit: 1763

Examiner:

R. Bueker

CERTIFICATE OF MAILING 37 CFR 1.8

RECEIVED

TC 1700 HA I hereby certify that this correspondence is being deposited on with the United States Postal Service as First Class Mail in an envelope addressed to: Assistant Commissioner for Patents, Washington, D.C. 20231.

Signature

DECLARATION UNDER 37 C.F.R. 1.132

I hereby declare that:

- I am an inventor of the above-identified patent application and an employee of 1. Applied Materials, Inc., the assignee of the present patent application.
- 2. I have a Master of Science in Mechanical Engineering from the University of Minnesota, and a Bachlor of Science in Mechanical Engineering from the University of Tehran. I have worked in the field of substrate processing for 9 years. I am currently an Engineering Manager at Applied Materials, Inc.
- 3. I have read the references cited by the Examiner in the pending application including U.S. Patent No. 5,709,753 to Olson et al. (hereinafter Olson); and U.S. Patent No. 5,904,952 to Lopata et al. (hereinafter *Lopata*).
- 4. Olson teaches a pump with a pumping capacity that is incapable of rapidly evacuating gas from a chamber as is required with the substrate processing apparatus

PATENT Atty. Dkt. No. APPM/2981/CPES/EPS/BG

described in the present application. *Olson* specifies that the pump used is a "Drytel Series dry pump manufactured by Alcatel, Inc." Attached as Exhibit I is a description of these pumps with their operating characteristics provided by the manufacturer. Using the information provided and assuming the pump is used to evacuate a load-lock chamber having a volume of 30 liters, the pump of Olson would require at least 3 minutes to pump down the chamber to a pressure of 100mT. The pump of the present invention on the other hand, because of its superior operating characteristics, can pump down the same chamber to the same pressure in as little as 15 seconds. As discussed in the application (page 9, lines 6-8), a load-lock chamber must be evacuated each time a new batch of substrates is placed in or removed from the chamber. This rapid, repeated pump down for a high throughput system like the one described in the application could not be achieved with the pump of *Olson* and there would be no motivation to use the pump of *Olson* in a high throughput setting.

- 5. In addition to the foregoing, the pump of *Olson* is not really a dry pump but is a combination of a diaphram pump and a molecular drag pump that does not exhaust gas to atmospheric pressure.
- 6. Lopata teaches a substrate processing apparatus using diffusion pumps and mechanical pumps. While the mechanical pumps are shown near the apparatus in the Figures of the patent, there is absolutely no description of the pumps or of their location in the patent document. The description does make it clear that the process is a CVD process and requires a pump capable of providing high flow rates. Absent some teaching to locate the pumps close to the chamber, design and engineering practice suggests the pumps be located remotely from the chamber as these prior art pumps are too large and noisy to be located near a processing apparatus.

As the person signing below, I hereby declare that all statement made herein are of my own knowledge and are true and that all statements made on information and belief are believed to be true; and further that these statements were made with the knowledge that willful false statements and the like so made are punishable by fine or



imprisonment, or both, under Section 1001 of Title 18 of the United States Code, and that such willful false statements may jeopardize the validity of the application or any patent issued thereon.

Full name of inventor:

Pedram Sabouri

Inventor's signature:

Pedram John

Date:

2,27,02

Residence:

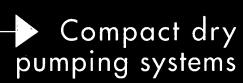
1554 Kooser Road

San Jose, CA 95118

Country of Citizenship:

USA

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DRYTEL series





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O Ompact Dry Pumping Sy m

Drytel series

Dry pumping unit

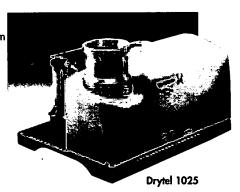
Drytel units are dry pumping systems including an Alcatel molecular drag pump (MDP) and an oil-free forepump. Designed to be used as bench top or easily integrated in a system, these units provide a dry clean vacuum from atmosphere to 10° mbar/Torr.

Small pumping configuration: Drytel 1025

p4à7

Based on the new "Open Concept", this unique, small and robust pumping system provides a suitable solution for backing turbomolecular pumps or pumping a system down to 10° mbar/Torr.

The Drytel 1025 accomodates a 7.5 l/s drag pump and a 1 m³/h diaphragm pump in a compact design.



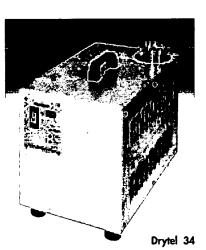
Large pumping configuration: Drytel 34 / Drytel 100

p8à11

Already used on numerous types of systems, these units are suitable for all applications which require a fast pumpdown time.

The Drytel 34 accomodates a 7.5 l/s drag pump and a 4 m³/h diaphragm pump.

The Drytel 100 accomodates a 24 l/s drag pump and a 4 $\rm m^3/h$ diaphragm pump.



Applications

Drytel series is recommended for all applications where a dry clean vacuum is required such as in industries (semiconductor, analytical instrumentation, pharmaceutical, chemicals, ...) and in Research and Development laboratories.

They can be used in various types of applications:

- Backing of turbomolecular pump
- Loadlock pumping
- Mass spectrometry
- Surface analysis
- lon pump evacuation
- Cryopump regeneration
- Calibration bench
- ...





"Open Concept": a new generation of Alcatel's turbo pumping group...



- OPEN Design
- OPEN Configuration
- OPEN Applications

Main advantages of the "Open Concept"

- Flexible possibility to get the most adaptated configuration
- Compact
- Easy to maintain direct access to the main components
- Cost effective

As a part of the "Open Concept" family, the Drytel 1025 has been designed to offer various configurations.

-Please consult-your Alcatel's

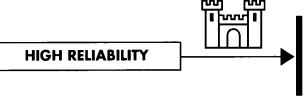
representative for more information on the available configurations.



NO CONTAMINATION FROM INTERNAL LUBRICANT



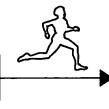
The two pumping stages working in series (MDP + diaphragm pump) don't require any fluid to operate, permitting use on ultra clean processes.



Drytel series accomodates well proven vacuum pumps:

- Alcatel molecular drag pump rotating at low rotationnal speed
- Rugged diaphragm pumps, already used by industry in thousands of harsh environments.

COST EFFECTIVE SOLUTION



Drytel series is the least expensive solution to achieve a clean vacuum down to 10° mbar/Torr.



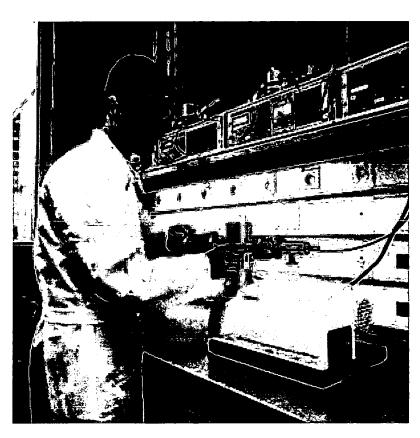
Small pumping configuration: Drytel 1025

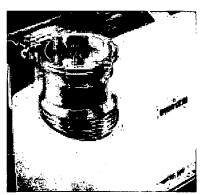
The Drytel 1025 is the first member of a new family based on the "Open Concept".

The Drytel 1025 is a new, small and robust pumping system which provides a suitable solution for backing turbomolecular pumps or pumping a system down to 10° mbar/Torr.

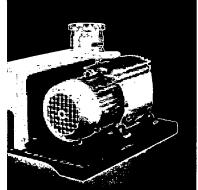
It accomodates a 7.5 l/s drag pump and a 1.5 $\rm m^3/h$ diaphragm pump in a compact design.







MDP 5011 (7.5 l/s) integrated on the Drytel 1025

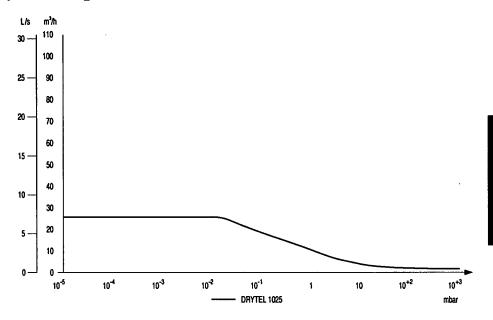


New 1.5 m³/h diaphragm pump

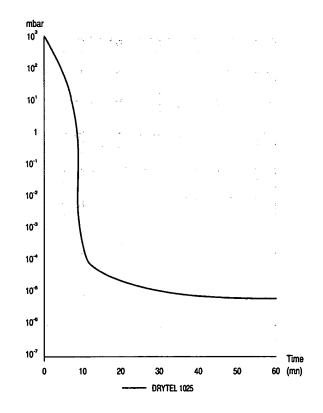


Technical data

Pumping speed / Inlet pressure (N₂)



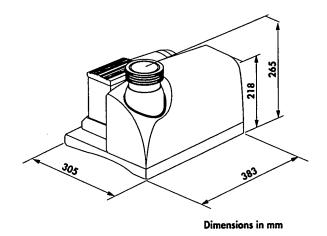
Pump down curves on a 30 l volume of N₂





Technical data

| Characteristics | | | Drytel 1025 |
|---------------------------------------|--|------------------|---------------|
| Ultimate pressure* | | mbar | 104 |
| Pumping speed < 10 ² mbar* | N ₂ He H ₂ | /s /s /s | 7.5 4 3 |
| Primary module pumping speed | _ | m³/h | 1 |
| Exhaust pressure | | mbar | Atmosphere |
| Start-up time | | min | 2 min |
| Cooling system | | | Air |
| Maximum inlet pressure | | mbar | 5 |
| Maximum ambient temperature | | °C | 0 to 35 |
| Maximum power consumption | | VA | 250 |
| Inlet flange | | | DN 63 ISO-K |
| Weight | | kg (lb) | 15 (33) |



Options and accessories

Options

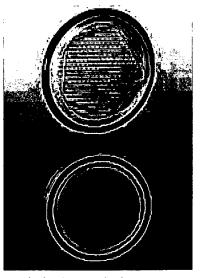
It is possible to fit the Drytel 1025 with several types of options:

- Interface board: allows the remote operation of the Drytel (start/stop and monitoring of the pumping system status),
- Automatic gas ballast: improves the pumping of light gases and reduces the condensation inside the Drytel,
- Exhaust connection: allows the collection of pumped gases to prevent their release to the atmosphere.

Accessories

Various accessories dedicated to the molecular drag pump can be offered as options. In particular, the inlet screen can be used to prevent foreign material to enter the pump.

| Description | P/N |
|--|--------|
| Inlet screen (DN 63) - 2.5 mm mesh | 039117 |
| Inlet dust filter 20 µ (DN 63) | 062912 |
| Aluminium centering ring (DN 63) special for MDP 5011 (without o-Ring) | 039212 |

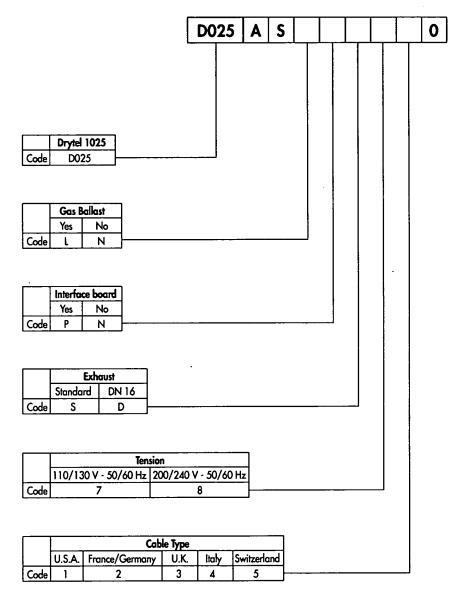


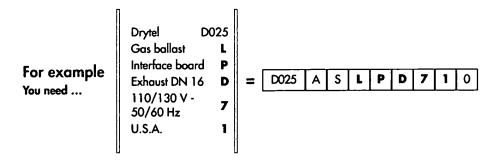
Standard & dense mesh inlet screen



^{*} Pneurop measurement

Ordering information







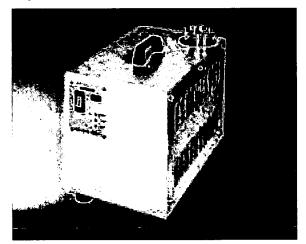
Large pumping configuration: Drytel 34 - Drytel 100

The Drytel 34 and the Drytel 100 provide large configurations for pumping down to 10° mbar/Torr at high pumping speed.

They accomodate a 4 m³/h diaphragm pump and an associated molecular drag pump (MDP), according to the requested configuration.

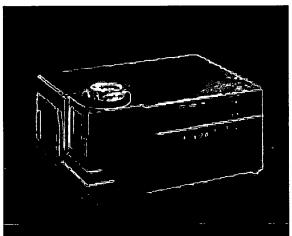
Specific versions are available for corrosive applications ("C" version equipped with a MDP chemical version).

Drytel 34



Drytel 34 equipped with a 7.5 l/s drag pump

Drytel 100



Drytel 100 equipped with a 27 l/s drag pump "C" version

1620 4/min

Technical data

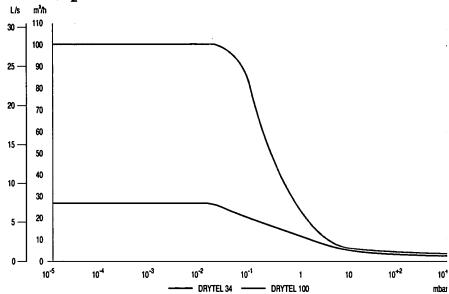
| Characteristics | |] | Drytel : | 34/34 C | Drytel 10 | 0/100 C |
|---------------------------------------|--|------------------|----------|---------------|-----------|-------------|
| Ultimate pressure* | | mbar | 104 | /10³ | - 1 | 04 |
| Pumping speed < 10 ² mbar* | N ₂ He H ₂ | /s /s /s | 7 | 7.5 4 3 | ī | 7 8 5 |
| Primary module pumping speed | · - | m³/h | , | 4 | : | 4 |
| Exhaust pressure | | atm | (103 | mbar) | (10° | mbar) |
| Start-up time | 1 | min | 2 | min | 1.5 | min |
| Cooling system | | | Air | Water | Air | Water |
| Maximum inlet pressure | | mbar | | 5 | 5 | 10 |
| Maximum ambient temperature | | °C | 0 to 35 | 0 to 50 | 0 to 35 | 0 to 45 |
| Maximum power consumption | | VA | . 5 | 75 | 6 | 50 |
| Inlet flange | | | DN 6 | 3 ISO-K | DN 10 | 0 ISO-K |
| Weight | 1 | kg (lb) | 36 | (80) | 43 | (95) |

^{*} Pneurop measurement

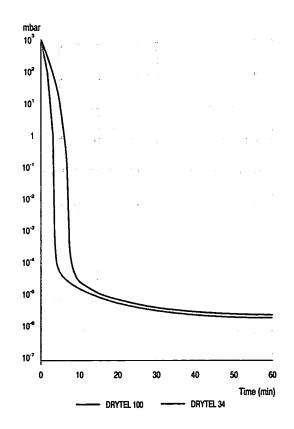


Technical data

Pumping speed / Inlet pressure (N₂)

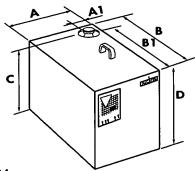


Pump down curves on a 30 l volume of N₂



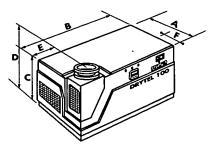


Dimensions





| Model | A | Αĩ | В | Bì | С | D |
|-------------|-----|----|-----|-----|-----|-----|
| Drytel 34 | 280 | 65 | 450 | 387 | 375 | 345 |
| Drytel 34 C | 280 | 65 | 450 | 387 | 375 | 345 |



Drytel 100

| Model | A | В | (c | D | E | F |
|--------------|-----|-----|-----|-----|----|----|
| Drytel 100 | 465 | 625 | 305 | 350 | 99 | 93 |
| Drytel 100 C | 465 | 625 | 305 | 350 | 99 | 93 |

Ordering information

| | | | Single phase | | | |
|--------------|------------------------|---------|-----------------------|----------------|-------------------|-------------------|
| Model | odel Flange Coo | | PART NUMBER | | | |
| Model | Tiunge | Cooling | 230 V (*) 50/60 HZ | 115 V 60 HZ | 100 V 50/60 HZ | 200 V 50/60 HZ |
| Drytel 34 | DN 63 ISO-K | Air - | 703310 | 793619 | 77933222 | 792025 |
| Drytel 100 | DN 100 ISO-K | Air | 795453 | 795454 | 795455 | 795457 |
| Drylei 100 | DIN 100 ISO-K | Water | 7725540 | 705541 | 7735542 | 793343 |
| Drytel 34 C | DN 63 ISOK | Air | 798614 | 798620 | 798623 | 798626 |
| D | DN 100 ISO-K | Air | 795909 | 795900 | 7959111 | 795913 |
| Drytel 100 C | MELIOU C DIN 100 150-K | Water | 795918 | 795914 | 795915 | 795917 |
| | | | | | | |

(*) Delivered with European power cord, for other power cords see below

Optional Power Cords

| Description | P/N |
|-------------------|----------|
| US power cord | |
| for 230 V - 60 Hz | 10741243 |
| US power cord | - |
| for 230 V - 50 Hz | 107405 |

Note

The Drytel 34 and the Drytel 100 can be customer specified with additionnal accessories.



Options and accessories

The Drytel 34 and Drytel 100 can be specified with a comprehensive range of additional accessories to meet customer requirements. Options are factory installed: they must be specified when ordering the Drytel. Accessories can be ordered separately.

Improving the performance:

- The manual or electrical (automatic) gas ballast improves the pumping of light gases, or reduces condensation inside the Drytel.
- The standard of dense mesh inlet screen should be used to prevent foreign material to enter the high vacuum pump.

Integration in a system:

- The exhaust connection collects the pumped gases to prevent their release to the atmosphere.
 If the gases are corrosive, a "C" type exhaust connection is appropriate.
- A separator kit may be used to separate the high vacuum pump from the Drytel.

Control:

The interface kits allow a remote operation of the Drytel (start/stop and monitoring of the pumping system status).

Others:

In any case, please contact us directly if your specific need is not covered by a standard product. We offer product customization and integration of accessories such as valves, gauges, etc...

Drytel 100/Drytel 100 C Options

| Di-ti- | Dr | ytel | PART | |
|--|-----|-------|---------|--|
| Description | 100 | 100 C | NUMBER | |
| Manual gas ballast valve between MDP and dry primary pump (light gases pumping) | • | | 050500 | |
| Electrical gas ballast valve 24 V-DC (other voltages on request) | • | • | 050580 | |
| Exhaust connection (DN 16) | • | | 050554 | |
| "C" type inert gas purge connector (DN 16 ISO-KF) and exhaust connection (DN 16) | • | | 062979 | |
| "C" type exhaust flange extension - Stainless steel / teflon | | • | 030577/ | |
| Interface control | • | • | 062898 | |
| Set of 4 casters | • | • | 032868 | |

Drytel 100/Drytel 100 C Accessories

| Description | Drytel 100/100 C | PART NUMBER |
|--|---|----------------|
| Set of 4 handles | • ; | 050590 |
| Inlet screen (DN 100) - 2.5 mm mesh | • | 050580 |
| Inlet dust filter 20 µ (DN 100) | - · · · · · · · · · · · · · · · · · · · | 050554 |

Drytel 34/Drytel 34 C Accessories

| Description | Drytel 34/34 C | PART NUMBER | |
|---|-------------------|----------------|--|
| Side (horizontal) inlet kit for MDP | • | 050591 | |
| Air cooling flow deflector | • | 050587 | |
| Inlet screen (DN 63) - 2.5 mm mesh | • | 039117 | |
| Inlet dust filter 20 µ (DN 63) | • | 062912 | |
| Aluminium centering ring (DN 63) special for MDP (without o-ring) | • | 0332112 | |

